

Micro Pattern Gaseous Detector: GEM & μ RWELL

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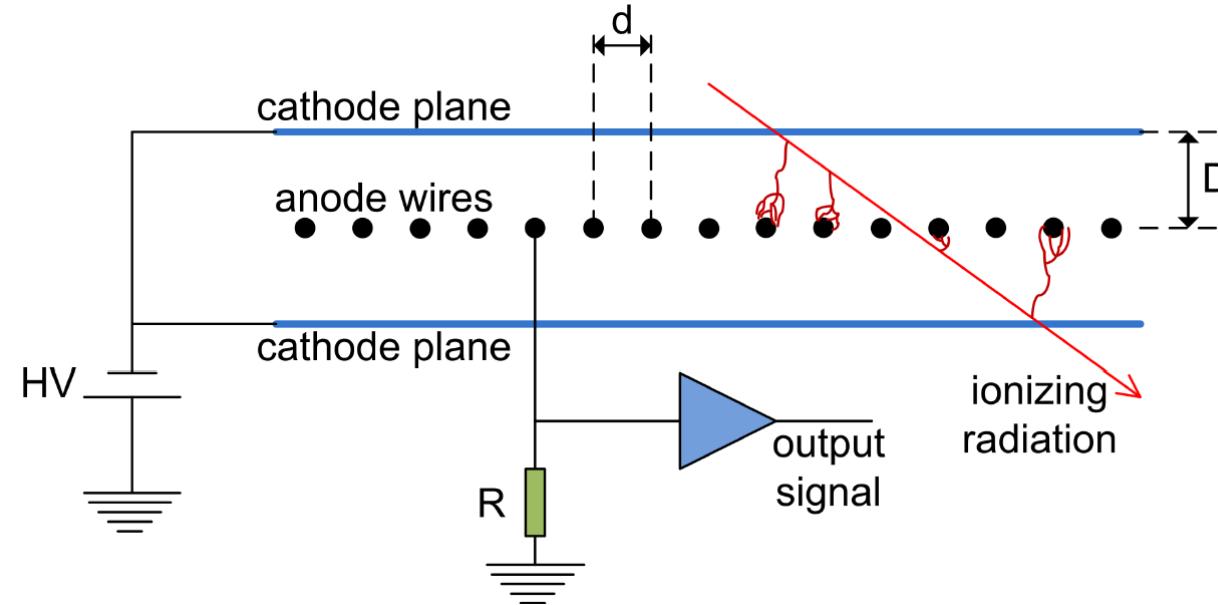
2026 / 02 / 06

입자검출기 워크샵 @ IBS

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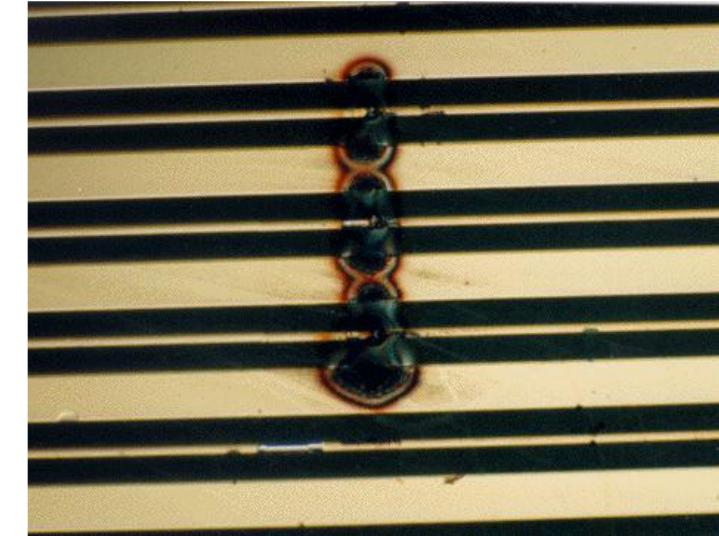
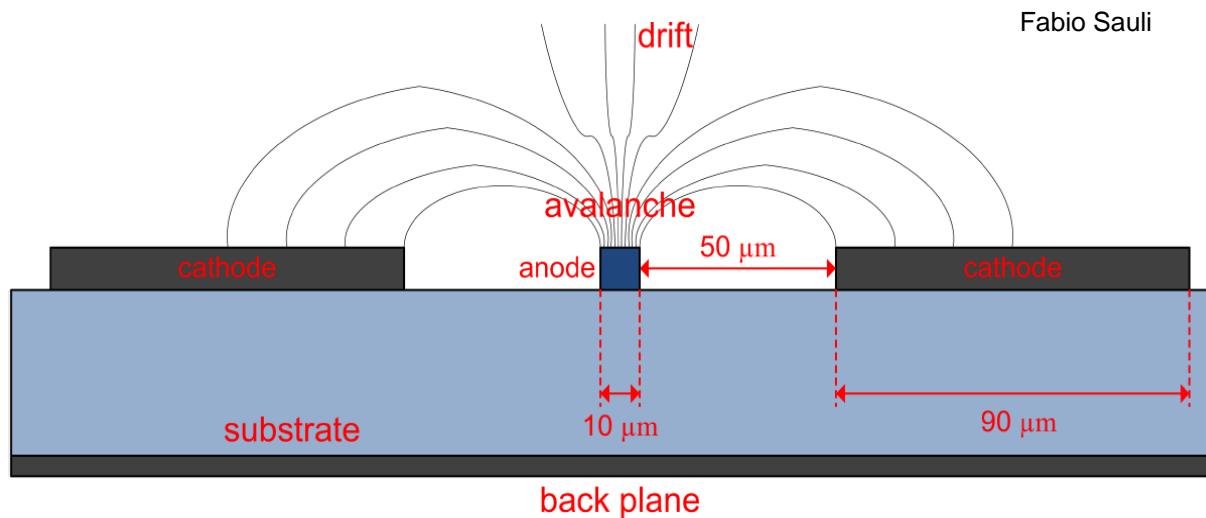
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- R&D status

1. Path to GEM & μ RWELL: MWPC



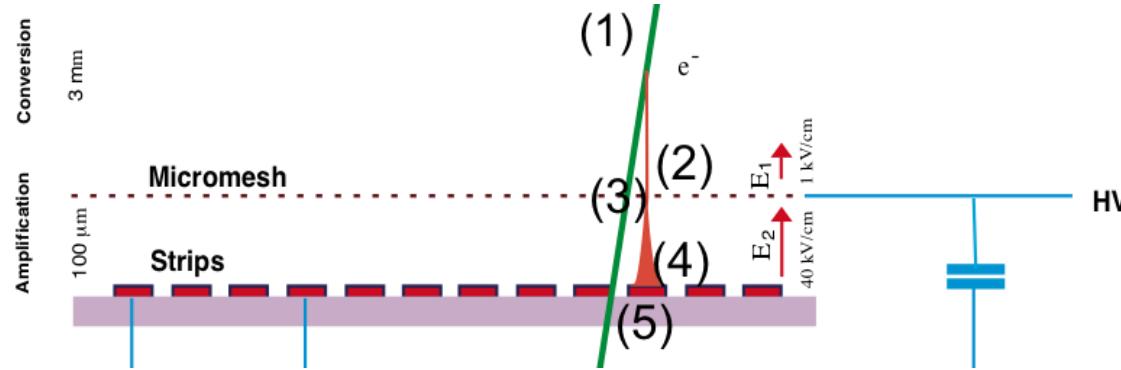
- Limitation of MWPC
 - Limited multi-track resolution $\sim O(2-2.5 d)$
 - Not enough rate capability $\sim O(\nu_{ion}/D)$
 - Not possible to decrease d and D due to wire buckling
- ⇒ Clear motivation for micro pattern electrode!
- Not mass production friendly

1. Path to GEM & μ RWELL: MSGC



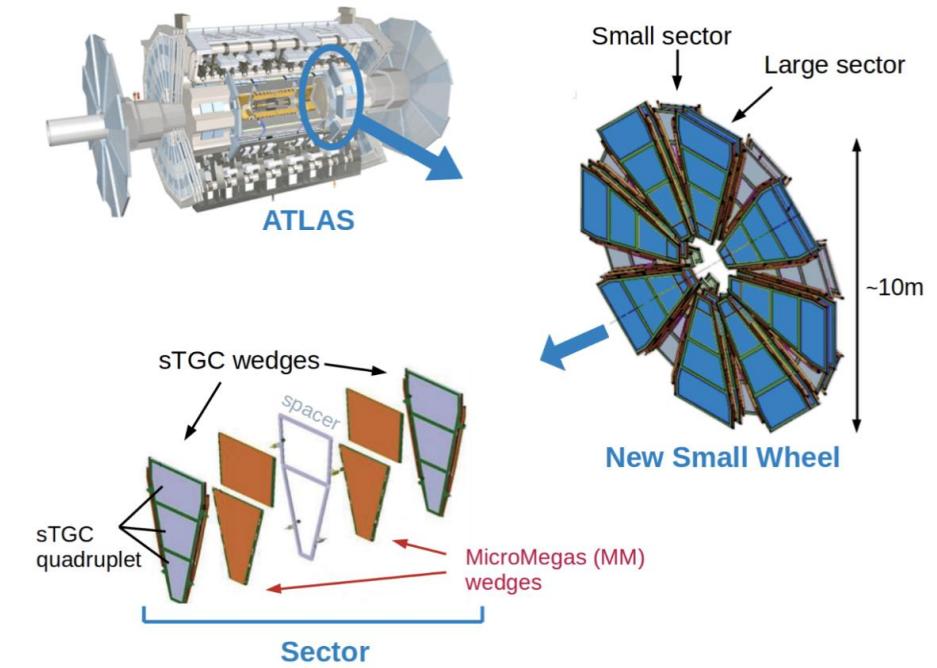
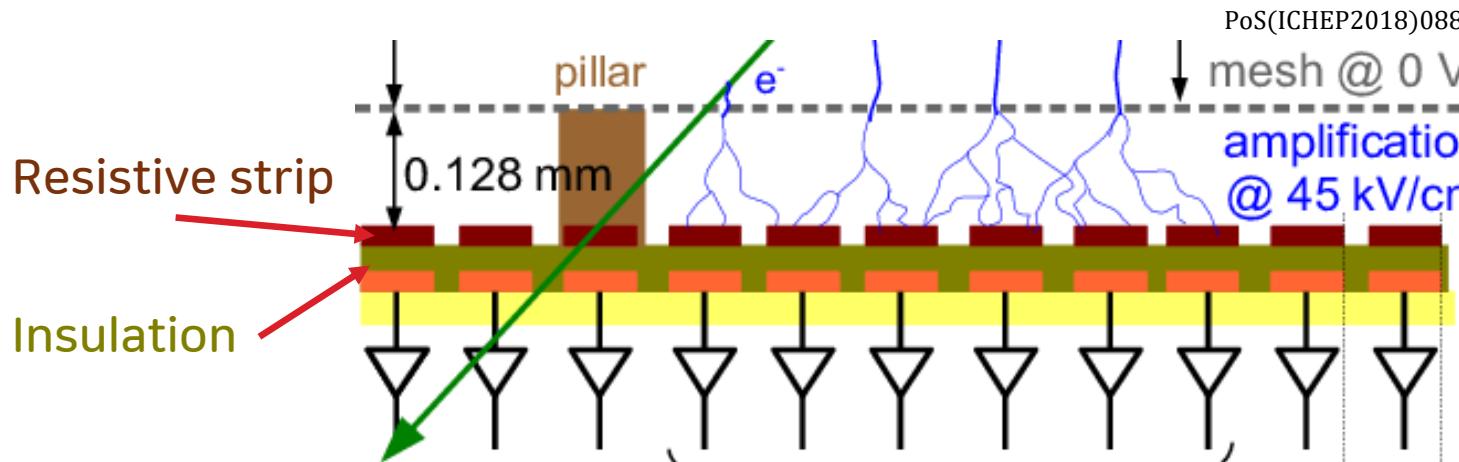
- $\times 100$ ($\times 20$) better rate capability (multi-track resolution) than MWPC
 - Also mass production friendly
- Short circuit problems caused by carbon paths formed on the substrate due to discharge

1. Path to GEM & μ RWELL: MM and R-MM



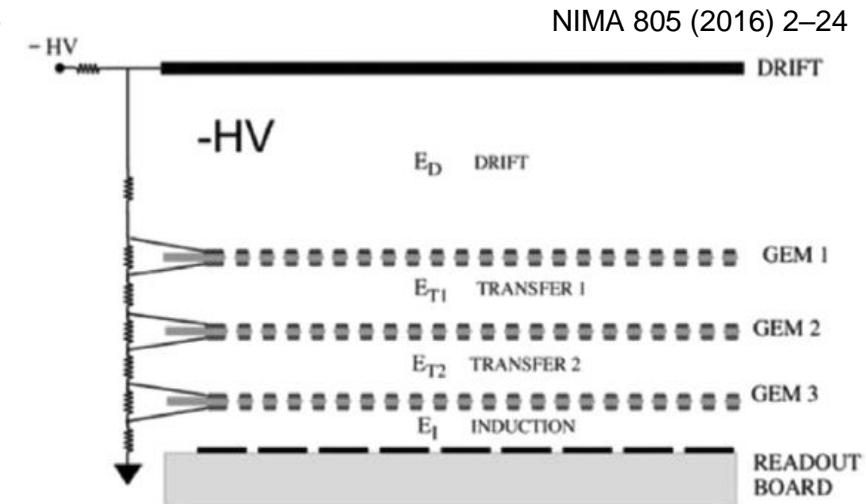
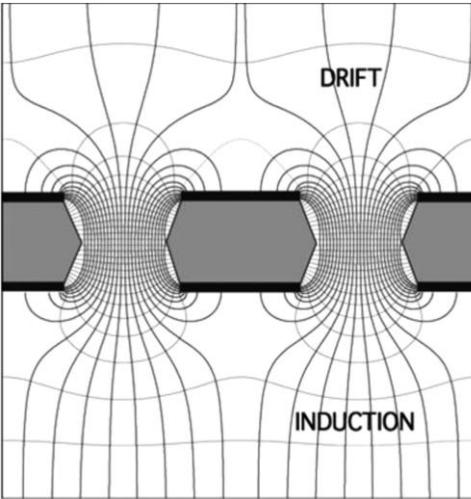
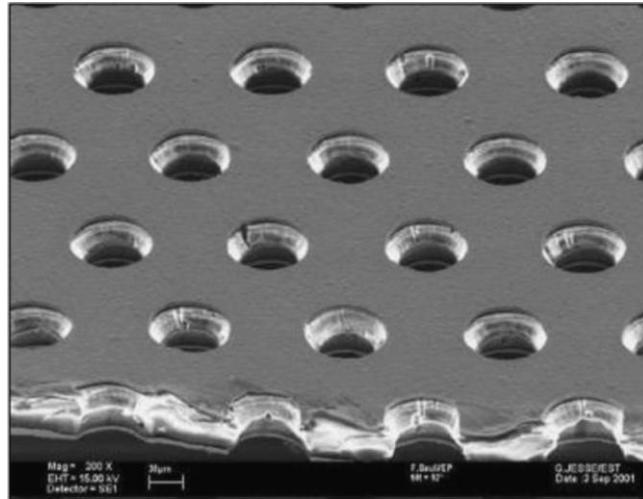
- Key concept of MM
 - If direct discharge on the substrate is causing carbon buildup, why not just lift the avalanche region off the surface?
- While the sensor achieved discharge tolerance, the readout electronics remained vulnerable
 - Experience of COMPASS
 - ⇒ Resistive MM!

1. Path to GEM & μ RWELL: MM and R-MM

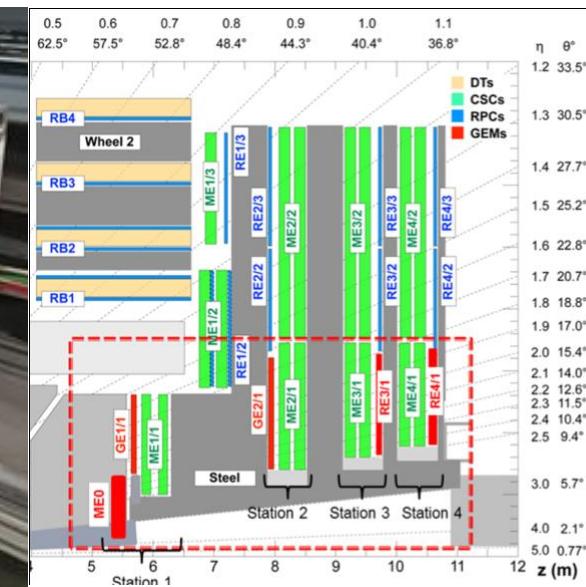
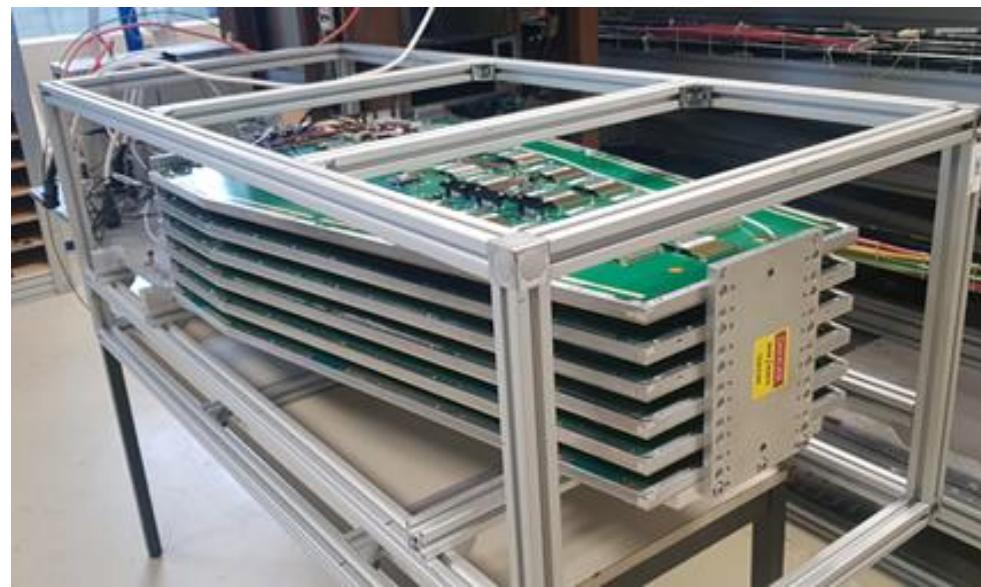


- The resistive anode strip induces a local voltage drop upon streamer formation, effectively quenching the discharge
 - RO electronics are protected!

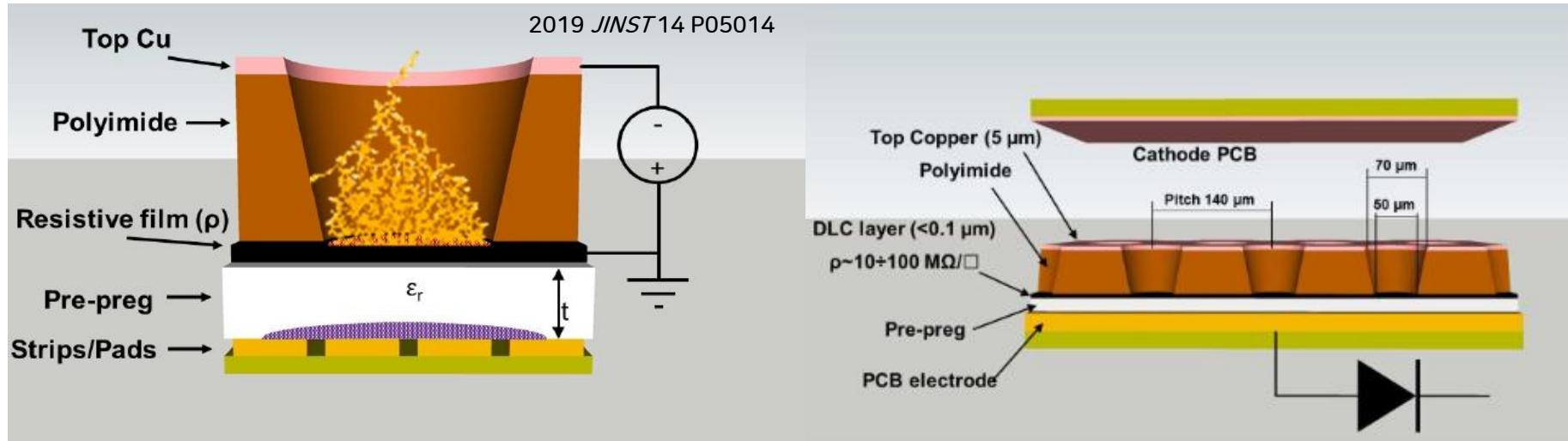
2. GEM



- Step-by-step amplification & separation of induction and amplification region
 - Extremely high rate capability
 - Extremely robust to aging



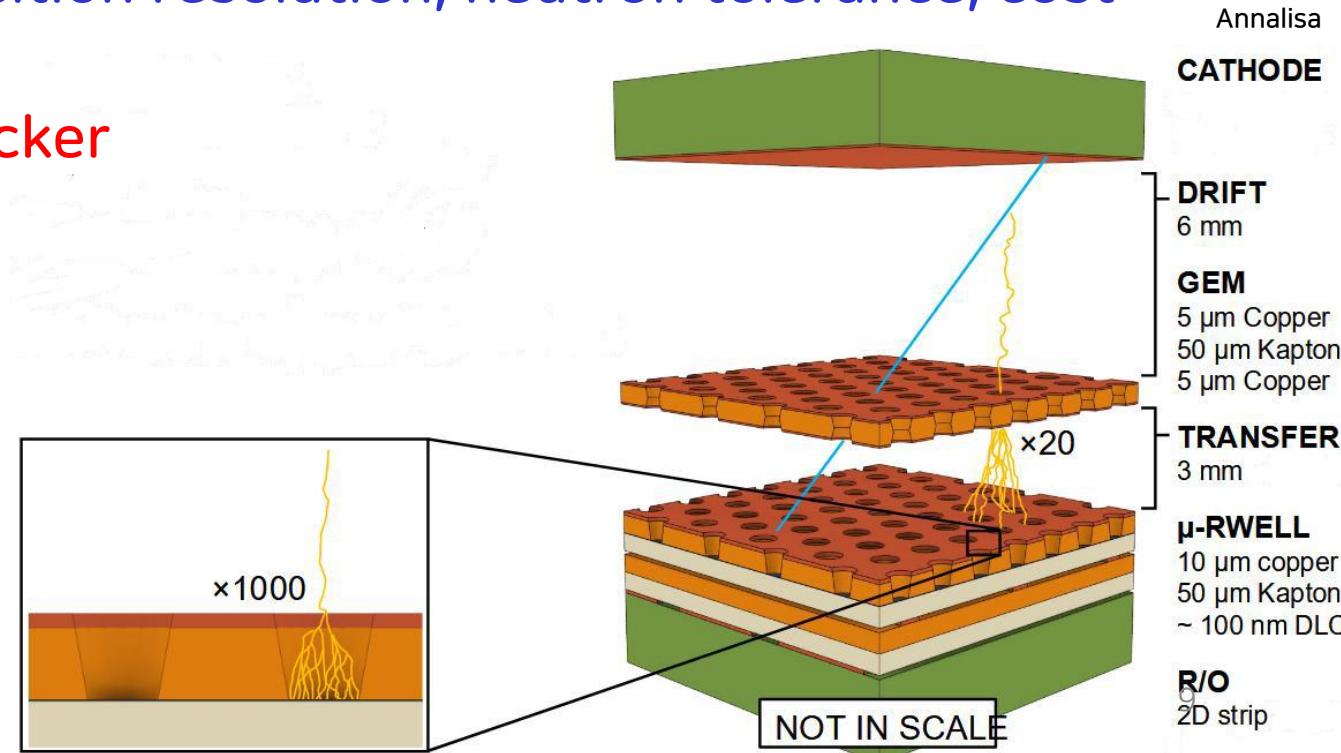
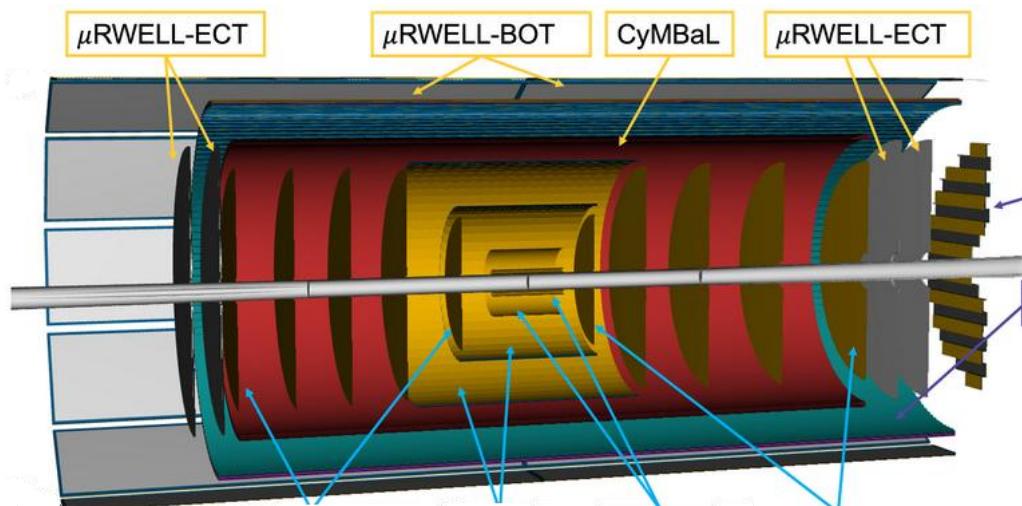
3. Resistive GEM - μ RWELL



- Micro resistive well, the resistive variant of GEM
 - Structurally simple and robust
 - Faster assembly and low material budget
 - Industry-friendly because it is based on standard PCB technology mostly
 - ⇒ Cost-effective
- However, having CERN as the single supplier creates a severe bottleneck in procurement

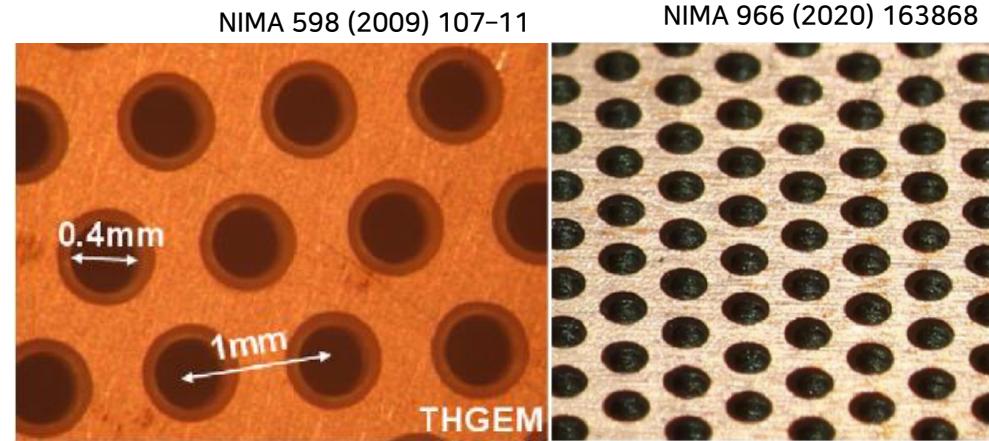
3. Resistive GEM - μ RWELL

- Experiment planning to use μ RWELL
 - ePIC central tracker: GEM+ μ RWELL hybrid, low material budget
 - LHCb muon tracker: GEM+ μ RWELL hybrid, replacing MWPC due to Lumi. upgrade, high rate μ RWELL
 - CLAS12 tracker: replacing DC due to Lumi. upgrade, high rate μ RWELL
 - DAMSA tracker & pre-shower: good position resolution, neutron tolerance, cost effective
 - IDEA @ FCC-ee pre-shower & muon tracker

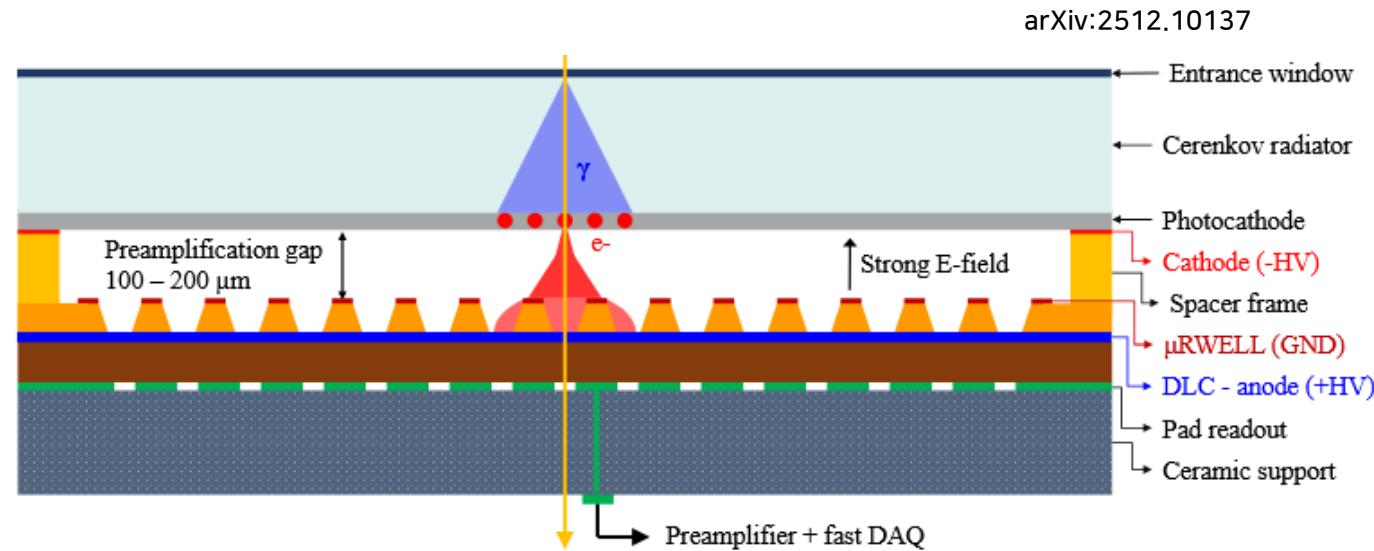


4. Other MPGDs

- THGEM
 - Robust, high gain, cheap, mass production friendly
 - Poor multi-track resolution, charging up, discharge
 - Glass THGEM?

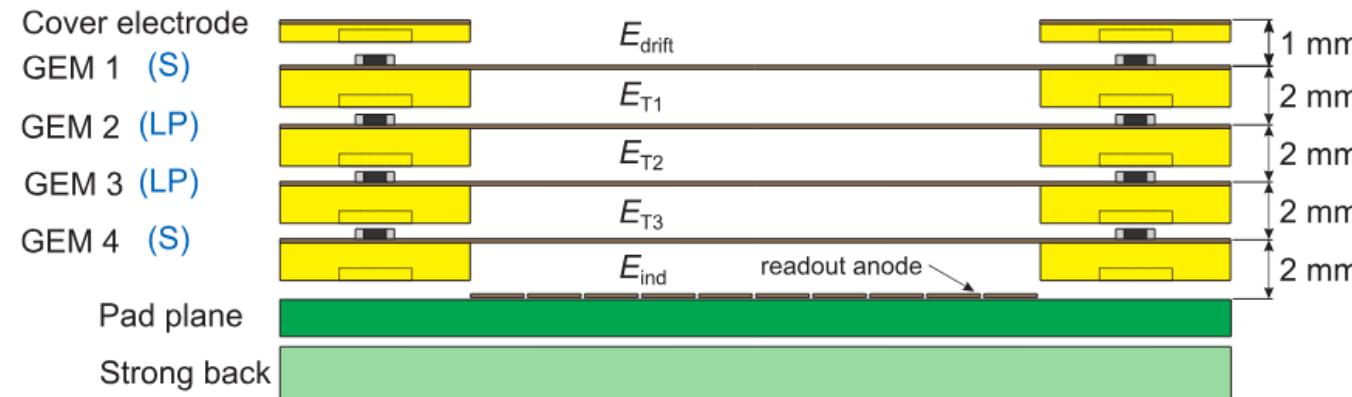


- PICOSEC
 - Cherenkov+photoelectric+MPGD
 - ~20 ps for CsI or
 - ~ 35 ps for DLC photocathode



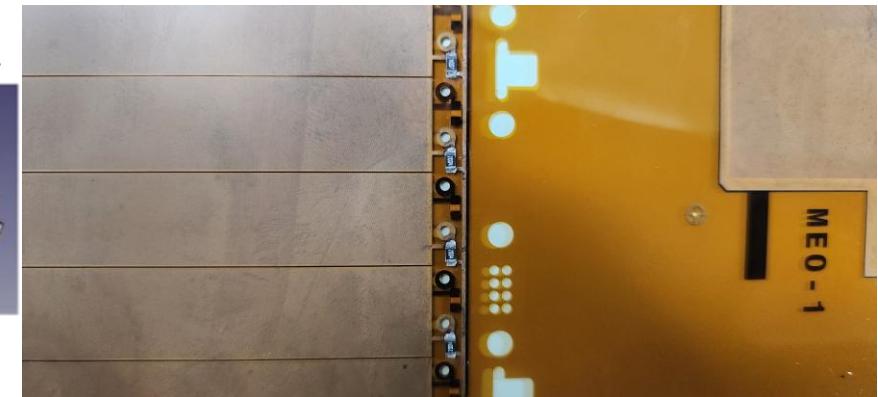
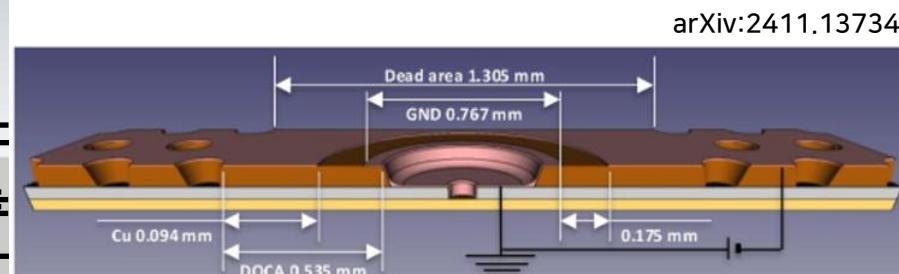
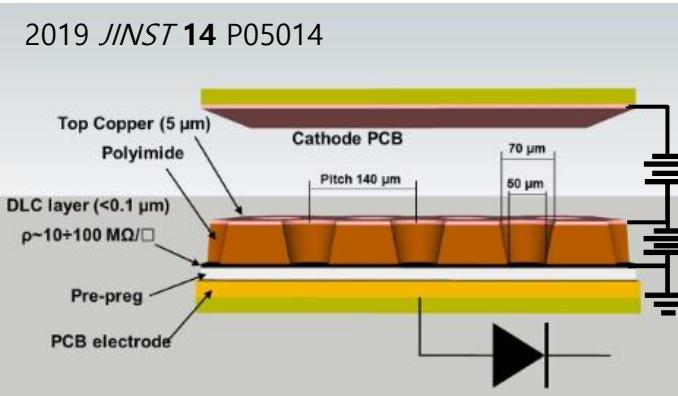
5. GEM vs. μ RWELL vs. R-MM

- In general, GEM, R-MM and μ RWELL exhibit comparable performance
 - Position resolution: $\sim 60 \mu\text{m}$
 - Energy resolution: R-MM $\sim \mu$ RWELL $>$ GEM
 - Time resolution: R-MM $\sim \mu$ RWELL $>$ GEM
- Aging: GEM \gg R-MM \sim μ RWELL
- Ion back flow: μ RWELL $>$ R-MM $>$ GEM
 - The ALICE continuous TPC achieved an ion backflow of 0.7% using 4 GEM readout

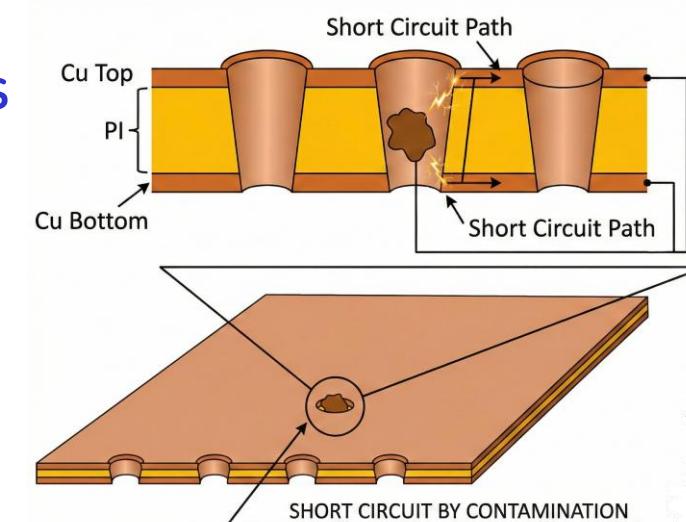


5. GEM vs. μ RWELL vs. R-MM

- Rate capability: GEM > μ RWELL \sim R-MM
 - GEM: voltage drop @ protection resistor, resistive detectors: voltage drop @ resistive layer

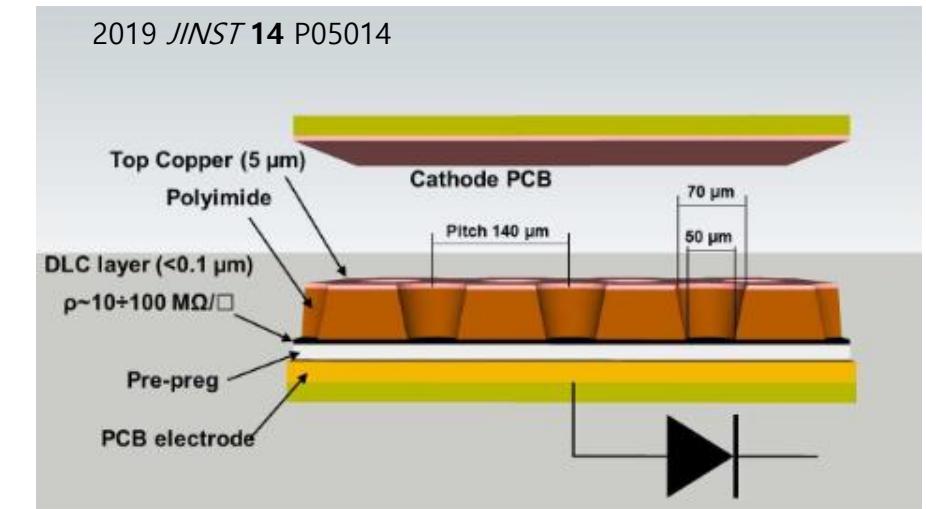
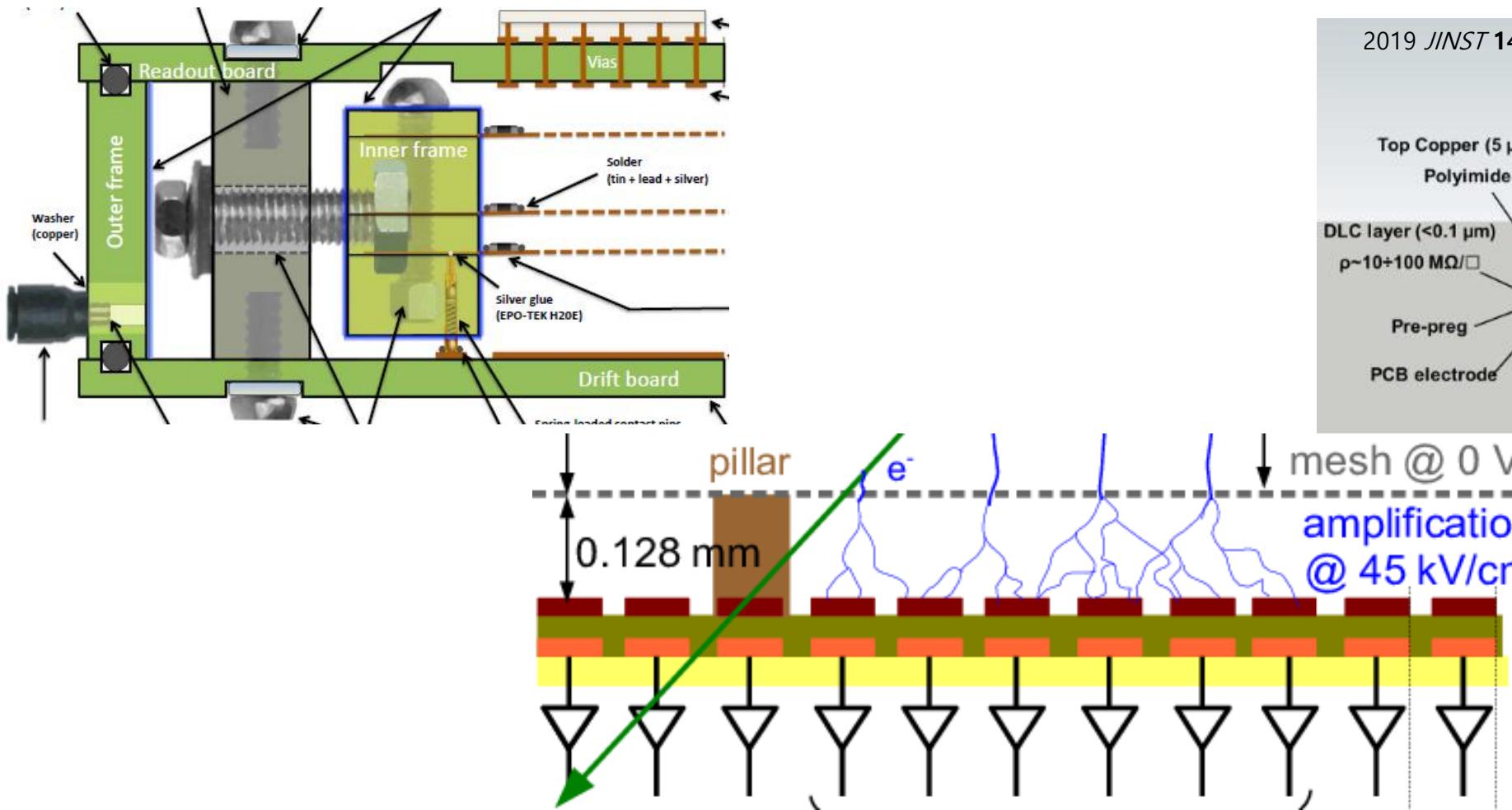


- Sector loss due to short circuit: μ RWELL \sim R-MM \ll GEM
 - A short circuit causes a full sector loss in GEMs, while it results in only a point loss for resistive detectors



5. GEM vs. μ RWELL vs. R-MM

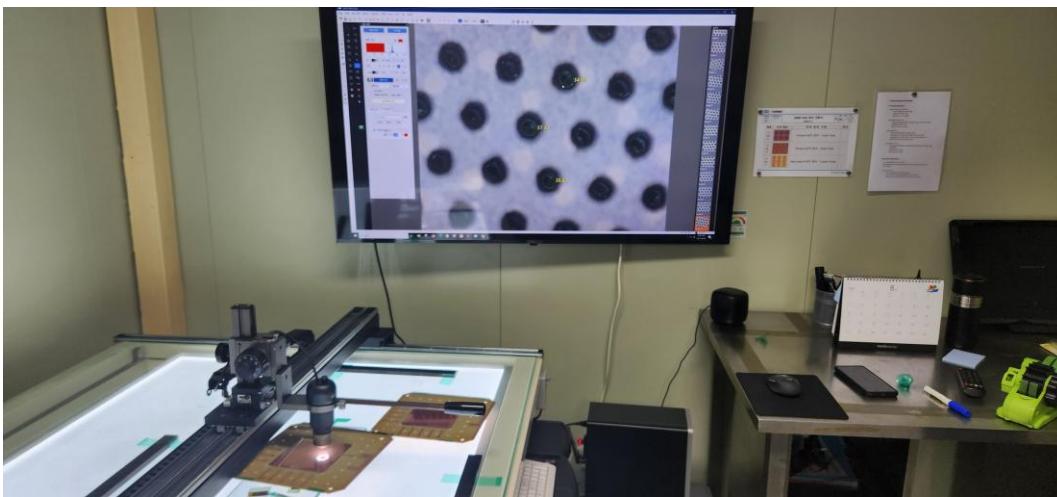
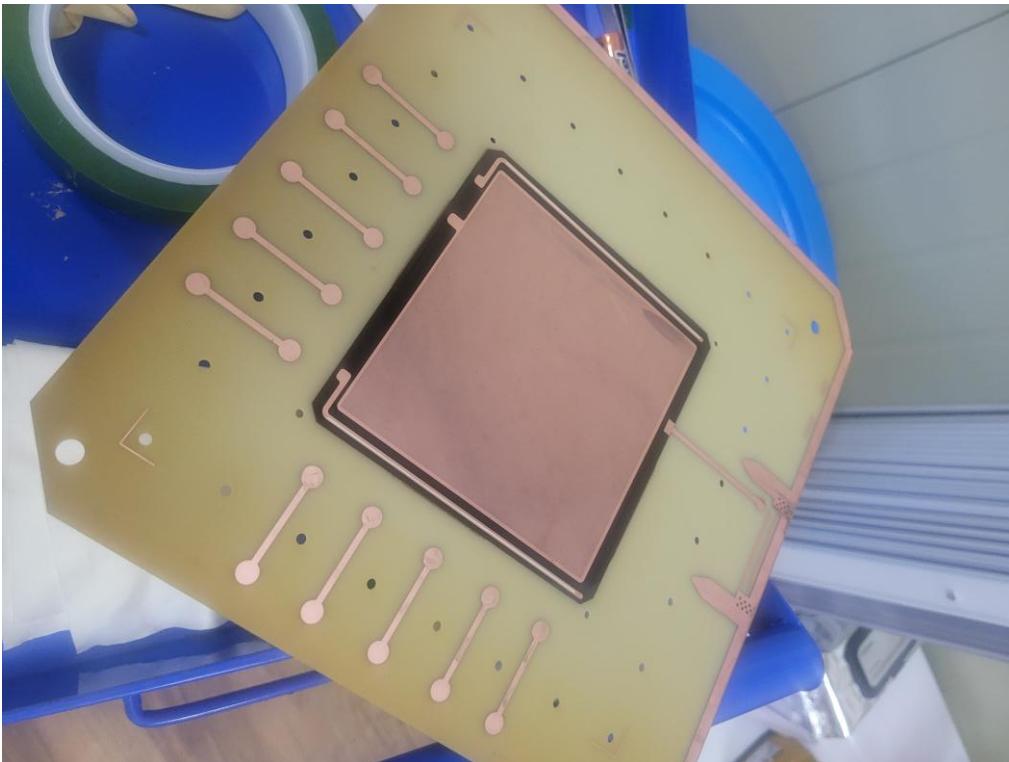
- Structural complexity: μ RWELL \ll R-MM $<$ GEM
 - So is material budget
 - Flexible μ RWELL using FPC based readout



6. Outlook

- μ RWELL is expected to become the most important detector in the MPGD
- The popularity of GEM is expected to decline significantly compared to now
 - μ RWELL is expected to replace a large share of GEM
 - No upcoming experiments that require the exceptional rate capability and aging resistance of GEM
 - Could GEMs be used as imaging detectors in industrial applications outside of physics?
 - Nevertheless, GEM technology will remain relevant for TPC and pre-amplifier
- R-MM usage may decline a bit, but it will continue to be a staple technology

7. R&D Status



Summary

- Efforts to improve the multi-track resolution and rate capability of gas detectors led to the birth of MPGD
- While various MPGDs are being researched, the most widely adopted technologies are GEM, R-MM, and μ RWELL
- I believe μ RWELL will become the most significant technology in the MPGD
 - Working on μ RWELL production research using the GEM manufacturing infrastructure available in Korea